# Controlling Morphology and Excitonic Disorder in Monolayer WSe<sub>2</sub> Grown by Salt-Assisted CVD Methods

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W metal flux, which is controlled by adjusting the mass ratio of  $WO_3$  to NaCl. This edge disorder then couples to excitonic disorder, which manifests as broadened and spatially varying emission profiles. Our work links synthetic parameters with analyses of material morphology and optical properties to provide a unified understanding of intrinsic limits and opportunities in synthetic 2D materials.

**KEYWORDS:** 2D materials, transition-metal dichalcogenide, chemical vapor deposition, crystal morphology, crystal defects, exciton, photoluminescence

# INTRODUCTION

Monolayer transition metal dichalcogenides (TMDs) are an attractive materials platform for optoelectronic, 1-3 nanoelectronic,<sup>4,5</sup> and quantum device studies.<sup>6-8</sup> Notably, TMD crystals are excellent candidates for exploring light-matter interactions at the 2D limit9 because they exhibit a direct bandgap in monolayer form,<sup>10</sup> a strong coupling of optical stimulation to excitonic states,<sup>11</sup> and spin–valley coupling.<sup>12</sup> While monolayers exfoliated from bulk crystals are commonly used for proof-of-concept devices and spectroscopic experiments, exfoliation frequently results in strained or torn crystals and rarely yields sample sizes greater than 100  $\mu$ m.<sup>13</sup> Direct bottom-up synthetic techniques involving chemical vapor deposition (CVD) offer a promising route toward scalable production of intact and larger area monolayer TMD crystals, which is vital to realization of these materials' transformative potential in science and technology.<sup>14</sup> In particular, recent breakthroughs in CVD growth of TMD monolayers have enabled researchers to precisely tune crystal properties through morphology and phase engineering.<sup>15–17</sup>

The reliability and impact of these synthetic methods are defined by the extent to which the relationship between synthetic parameters and resulting material properties is understood. The presence of grain boundaries, intrinsic strain, and lattice defects in the synthesized samples remains an outstanding challenge. These imperfections have immense consequences for the properties of monolayer TMDs<sup>18-20</sup> and often render them of insufficiently high quality to supplant exfoliated crystals in champion device studies.<sup>21</sup> Strain often arises in synthesized 2D TMDs either due to thermal mismatch between the crystal and its growth substrate or due to bending of the crystal over rough substrates.<sup>22,23</sup> Moreover, ordered vacancies or defects, which can act as scattering sites for excitons and charge carriers, are often located at grain boundaries formed when multiple growing crystals intersect.<sup>18,19</sup> Finally, while synthetic monolayers can express unfragmented native crystal edges that express catalytically or electronically active atomic terminations,<sup>24</sup> imbalanced precursor fluxes during growth can alter the edge structure leading to excess free carriers which enhance trion and biexciton emission.<sup>25,26</sup> The termination of crystal edges or boundaries also offers tantalizing prospects for designing nontrivial states which differ from the bulk such as gap-states,<sup>2</sup>

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Figure 1. (a) Summary of the 2D TMD crystal synthesis parameter space explored by other researchers and their observed crystal morphologies. The relative position of each crystal schematic within a referenced data set is an accurate estimate of the parameter space within which that crystal was prepared. The scheme diagonal represents a 1:2 M:X ratio. With the exception of this work (red), each reference study was conducted on MoS<sub>2</sub>. (b) Thermogravimetric analysis (TGA) data collected on W precursor samples prepared at WO<sub>3</sub>:NaCl ratios of 5:1, 10:1, and 15:1. The first minimal mass loss event at ~400 °C can be attributed to a minor impurity that is inconsequential to the reaction. (c) Powder X-ray diffraction (pXRD) data collected on W precursors prepared across a range of WO<sub>3</sub>:NaCl ratios. Also included are calculated pXRD scans of Na<sub>x</sub>WO<sub>3</sub> bronzes from ref 40. (d) Dark-field optical images of WSe<sub>2</sub> crystal sgrown at high WO<sub>3</sub>:NaCl ratios. Schematic: Competition in the rate of growth of  $W_{zzz}$  and Se<sub>zz</sub> edges defines the range of 2D WSe<sub>2</sub> crystal shapes and facet terminations. Scale-bars: 10  $\mu$ m.

metallic<sup>28</sup> or ferromagnetic<sup>29</sup> edges, and topological states at grain boundaries,<sup>30</sup> all of which have been observed in WSe<sub>2</sub>. Since strain, lattice defects, and edge inhomogeneities hamper device performance, synthetic strategies addressing these sources of disorder are urgently needed.

Precursor flux at the crystal growth front is a critical determinant of the morphology, defect density, and edge termination of TMD crystals.<sup>31–33</sup> The relative fluxes of transition metal (M) and chalcogen (X) precursors define a diverse array of TMD crystal shapes and sizes (Figure 1a). For example, if there is relative parity in the flux of M and X precursors, then one expects roughly equivalent growth rates for the thermodynamically stable M-terminated or X-terminated zigzag edges ( $M_{zz}$  and  $X_{zz}$ ), which lead to hexagon-or triangle-shaped TMD crystals.<sup>34</sup> Much of this parameter space has been studied extensively for the case of Mo-based TMDs.<sup>35–38</sup>

A major reason for the shortfall in synthetic studies examining W-based TMDs is the difficulty in evaporating WO<sub>3</sub>, the most common precursor for WX<sub>2</sub> crystals.<sup>39</sup> One strategy to circumvent this challenge is to mix alkali metal

halide salts with WO<sub>3</sub> to form a more volatile precursor<sup>40,41</sup> which can be used in CVD growth of WS<sub>2</sub> and WSe<sub>2</sub> crystals. While this strategy has been shown to yield triangle-shaped and hexagon-shaped WX<sub>2</sub> crystals, studies reporting crystals with unusual morphologies<sup>40,41</sup> and serrated edges have not commented on the chemical origin of these growth features.

Here, we show that precise tuning of the volatility of the W precursor through adjustment of the WO<sub>3</sub> to NaCl ratio allows systematic control of TMD (in this case WSe<sub>2</sub>) crystal morphology. We also examine the dependence of the crystal emission properties on morphology and local defects through photoluminescence mapping. Our results not only provide much-needed insights regarding morphology control of W-based TMDs, which have received much less attention, but also establish a rigorous connection between synthetic parameters and their influence on TMD optical properties.

## RESULTS AND DISCUSSION

We first examined the structure and volatility of mixtures of  $WO_3$  and NaCl. For all syntheses we discuss below, the NaCl amount is fixed, and  $WO_3$  is varied to alter the precursor ratio.



**Figure 2.** (a) SEM images of WSe<sub>2</sub> crystals grown from W precursors prepared at different WO<sub>3</sub>:NaCl ratios. The images are listed in order of increasing W volatility (decreasing the WO<sub>3</sub>:NaCl ratio). Scale-bars: 5  $\mu$ m (12:1), 20  $\mu$ m (10:1, 8:1, 6:1), 10  $\mu$ m (4:1). (b) Histograms of the number of protrusions per  $\mu$ m of crystal edge length as surveyed from wide-field SEM images collected on samples prepared at each ratio indicated in the top right. (c) Schematic proposal of the growth mechanism for 2D crystals with jagged edges. A seed (pink dot) is formed first and is composed of the tungsten oxychloride deposit, which steadily alloys with the steady-state flux of Se (yellow line). Following this, WSe<sub>2</sub> grows in an environment of high W flux (blue line), yielding a 2D crystal with W<sub>zz</sub>-terminated facets. As the reaction progresses, the W flux drops relative to the Se flux as the seed becomes steadily depleted of W. This imbalance results in accelerated growth of W<sub>zz</sub> edges and concomitant expression of Se<sub>zz</sub>-terminated protrusions.

Low ratios of WO<sub>3</sub>:NaCl exhibit onset of mass loss at lower temperatures than pure WO<sub>3</sub> as determined by thermogravimetric analysis (TGA). Specifically, samples containing a WO<sub>3</sub>:NaCl ratio of 5:1 (the lowest we tested by TGA) lose nearly 10% of their mass before the highest ratio of 15:1 loses 1% of its mass (Figure 1b). Powder X-ray diffraction (pXRD) scans of samples composed of a range of annealed mixtures of WO<sub>3</sub> and NaCl reveal several details (Figure 1c). A triplet of peaks at  $2\theta = 22^{\circ}$  and a series of broadened peaks at  $2\theta = 33^{\circ}$ merge into single peaks at  $2\theta = 23.4^{\circ}$  and  $2\theta = 33.25^{\circ}$  in samples containing WO<sub>3</sub>:NaCl ratios below 20:1. Reflections in the WO<sub>3</sub> diffraction pattern are consistent with the calculated pattern for triclinic WO<sub>3</sub>,  $^{42}$  which shows three prominent peaks around  $2\theta = 22^{\circ}$  from the (200), (020), and (002) planes and collections of weaker peaks at higher angles which merge into broadened peaks in the experimental diffraction pattern (Figure S1). In diffraction patterns collected from annealed WO<sub>3</sub>:NaCl mixtures, the two most prominent peaks around  $2\theta = 23^{\circ}$  and  $2\theta = 33^{\circ}$  associated with the 15:1 sample agree well with reflections from the (100) and (110) planes observed in Na<sub>x</sub>WO<sub>3</sub> bronzes studied by Straumanis.<sup>43</sup> Moreover, we observe peak shifts to lower  $2\theta$  as the WO3:NaCl ratio decreases, and this trend is consistent with incorporation of higher Na concentrations in these mixtures.<sup>43</sup> These data provide evidence for the formation of a new, more volatile, crystalline phase upon increasing incorporation of Na (lower WO<sub>3</sub>:NaCl ratios) and suggest that  $Na_xWO_{(3-x)}Cl_x$  is the volatile W precursor species formed during salt-assisted CVD growth of W-based TMDs. An alloy of this form has been postulated, without compelling experimental evidence, to

be the intermediate in salt-assisted TMD reactions.<sup>44</sup> These experiments establish a strategy for tuning the W flux through control of W precursor volatility.

To examine how crystal morphology evolves with W flux, we conducted WSe<sub>2</sub> syntheses across a range of WO<sub>3</sub>:NaCl ratios. For every reaction discussed below, the degree (low or high) of the W flux is considered relative to the Se flux, with the latter being held constant across all syntheses. We first examined reactions conducted at "low" W flux, which we associate with WO3:NaCl ratios higher than 15:1. Crystals evolve from welldefined triangular shapes at ratios of 35:1 (lower W flux) to triangular shapes with flattened corners at ratios of 15:1 (higher W flux), as seen in dark-field optical images (Figure 1d). The triangle-shaped crystals likely have Se<sub>zz</sub>-terminated facets, since the growth rate of  $W_{zz}$  edges exceeds that of  $Se_{zz}$ edges when the W flux is relatively lower than that of Se. Kinetic Monte Carlo calculations predict faster metal<sub>zz</sub> over chalcogen<sub>27</sub> facet growth and attribute this to preferential metal adsorption on metal<sub>zz</sub> edges saturated with under-coordinated chalcogen atoms, which is to be expected under our conditions of excess chalcogen flux.<sup>38</sup> The onset of flattened corners in the crystals can be associated with Wzz-terminated facets that begin to appear as the growth rate of  $Se_{zz}$  edges becomes competitive with that of  $W_{zz}$  edges when the W flux approaches that of Se. This competition between facet growth rates determines the ultimate crystal shape and is summarized in the schematic of Figure 1d. Our observations of growth within the "low flux" regime are consistent with reports tracing the evolution of crystal shape as reaction conditions shift from substantial chalcogen excess to W:Se ratios of 1:2.<sup>34,38</sup>

We next examined WSe<sub>2</sub> crystal growths conducted at "high" W flux conditions (WO<sub>3</sub>:NaCl ratios less than 15:1). A WO<sub>3</sub>:NaCl ratio of 12:1 yields nearly hexagonal crystals, in accordance with the trend discussed above (Figure 2a). This observation suggests roughly equivalent growth rates for W<sub>zz</sub>-and Se<sub>zz</sub>-terminated facets as the W flux and Se flux reach parity. One would predict that further increasing the W flux through lower WO<sub>3</sub>:NaCl ratios should increase the growth rate of the Se<sub>zz</sub> edges such that the crystal assumes a triangle shape with W<sub>zz</sub>-terminated facets.

However, as the W flux is increased by using WO<sub>3</sub>:NaCl ratios less than 10:1, we observe the onset of anomalous crystal growth modes. Notably, for ratios less than 10:1, SEM images reveal that protrusions begin to grow from the crystal edges (Figure 2a). The density of these protrusions per unit edge length increases sharply as the WO3:NaCl ratio decreases below 8:1 (Figure 2b) until the crystals exhibit a fractal-like edge morphology. Low-magnification SEM and optical images (Figures S2, S3) and statistical analyses (Figure 2b) confirm that these trends persist over many sampled crystals. These jagged edges are similar to those reported by other groups for the case of WX<sub>2</sub> crystals grown with alkali metal halide promoters.<sup>40,41</sup> A closer analysis suggests that the protrusions are terminated by  $Se_{zz}$  facets, which are opposite to the  $W_{zz}$ facets expressed by the "parent" crystal from whence the protrusions nucleated (Figure S4). As stated above, we expect that high W fluxes should yield crystals with  $W_{zz}$ -terminated facets due to rapid Sezz edge growth. The observation that the protrusions exhibit mirror symmetry (Figure S4) about the edge axis further supports the expectation that the protrusions are Sezz-terminated.

The WSe<sub>2</sub> crystal morphology can serve as a reporter on the relative growth rates of the  $Se_{zz}$  and  $W_{zz}$  edges and can be used to construct a timeline and mechanism for the anomalous growth observed during synthesis at low WO<sub>3</sub>:NaCl ratios (Figure 2c). High-resolution SEM images of reactions run for 1 min, as compared to 3 min for the full reaction, contain incipient crystals with large seeds at their center (Figure S5). These data suggest a first stage of growth (Figure 2c, purple region) that involves an induction period during which the volatile tungsten oxychloride species deposited on the Si/SiO<sub>2</sub> substrate form alloys with  $Se^{32,45-47}$  and seed the WSe<sub>2</sub> crystal growth. Moreover, analysis of a sample prepared at a 6:1 WO3:NaCl ratio reveals predominantly jagged-edged crystals and some straight-edged triangular crystals which have average edge lengths of 41.7  $\pm$  0.9  $\mu$ m and 15.1  $\pm$  0.6  $\mu$ m, respectively (Figure S6). The smaller straight-edged crystals are likely the result of reaction that progressed through the end of a second stage of growth (Figure 2c, violet/blue region) that can be associated with a high flux of W to the crystal growth front from the W-rich seed at early times. These straight-edged triangular crystals most likely possess W<sub>22</sub>-terminated facets, given that high relative W flux yields faster  $Se_{zz}$  edge growth. The larger jagged-edged crystals point to a third stage of growth (Figure 2c, green region), during which uneven facet growth takes place. We attribute the nucleation and growth of the protrusions to reduction of W flux relative to Se flux at the crystal edge, as the tungsten oxychloride seed is depleted of W. This is expected to lead to accelerated growth of  $W_{zz}$  edges with concomitant expression of Sezz-terminated facets. At longer times, as the seed becomes more fully depleted, the imbalance between the growth rates of  $Se_{zz}$  edges and  $W_{zz}$ edges increases further and leaves many parts of the W<sub>zz</sub> edges

terminated by under-coordinated Se. These latter edges are thermodynamically unstable and serve as nucleation sites for growth of the protrusions, which rapidly become terminated by  $Se_{zz}$  facets due to excess Se. The stochastic pattern of the protrusions may be due to the inhomogeneous distribution of the W precursor along the crystal growth front or the presence of random defects that serve as nucleation centers.

We tested this hypothesis by conducting timed reactions at 1 min intervals and characterizing the crystal products by SEM (Figure S5). For reactions run for 1 min at the growth temperature, we observe crystals with highly disordered growth fronts and prominent seeds at their center. After 2 min, the monolayer crystal coalesces into its expected triangular shape with a large central seed still present. After 3 min, the seed size is significantly reduced and jagged edges begin to emerge. We note that these experiments were conducted at a lower temperature in order to slow the reaction kinetics and thereby allow for temporal resolution of the crystal growth progress.

To provide additional evidence for our proposed mechanism and related edge assignments, we conducted aberrationcorrected high-angle annular dark field scanning transmission electron microscopy (HAADF-STEM) at the intersection of a WSe<sub>2</sub> crystal with one of its edge protrusions (Figure 3a, Figure S7). High-resolution and Fourier-filtered HAADF-STEM images and corresponding pixel contrast variations viewed along the arm-chair direction of the lattice within both the "parent" crystal and the protrusion reveal the same crystal orientation and expected 2H phase throughout these two regions (Figure 3b,d,e,g). We assign the brighter atoms as W and darker atoms as Se due to the larger expected scattering cross-section of W compared to two stacked Se atoms. By superimposing the WSe2 structure on a lattice-resolved image of the crystal, we can clearly identify the orientation of the lattice and index all directions and planes (Figure 3c,f). Using these data as a reference point, we can assign the protrusion (region "d" in Figure 3a) to Se-terminated zigzag edges and the parent crystal (regions "b" and "e" in Figure 3a) to Wterminated zigzag edges. While we cannot rule out the possibility that some edge protrusions arise due to mirrortwin boundaries, possibly arising due to the dramatic change of precursor flux, our HAADF-STEM data do not reveal the presence of such boundaries. In short, our results support the conclusion that the WSe<sub>2</sub> crystal lattice orientation is preserved across the parent crystal and its protrusions and that the edges of the protrusion are Sezz.

To identify any structural or topographical anomalies associated with crystals grown for WO3:NaCl ratios below 10:1, we collected Raman maps and atomic force microscopy (AFM) scans. Raman maps imaging the characteristic E' mode of WSe<sub>2</sub> (250 cm<sup>-1</sup>) reveal that the intensity of this mode is uniform across each crystal for every synthesis condition (10:1, 8:1, 6:1, and 4:1 ratios), with no noticeable intensity anomalies near the crystal edges (Figure 4a-d). Point and line spectra taken for crystals prepared at each of the aforementioned synthesis conditions reveal exceptionally uniform Raman responses (Figure 4e, Figure S8). AFM maps reveal that the crystals are of uniform height and, with the exception of isolated regions of bilayer growth, are largely monolayers with heights of 1 nm (Figure 4f-i). High-resolution AFM maps and line scans show no evidence of grain boundaries or height anomalies at the junctions between protrusions and their parent crystal (Figure 4j, Figure S9). The foregoing Raman and AFM data suggest that the crystals are continuous and



Figure 3. (a) HAADF-STEM image of the intersection between a parent 2D WSe<sub>2</sub> crystal and one of its protrusions. The TEM sample was prepared by transferring a crystal to a perforated silicon nitride membrane. Regions "b" and "e" are within the parent crystal, and region "d" is within the protrusion. Scalebar: 50 nm. (b) Highresolution, Fourier-filtered HAADF-STEM image from the whiteboxed region labeled "b" in (a). Scalebar: 4 nm. (c) Zoomed-in image of the white-boxed region in (b) with a cartoon of the WSe<sub>2</sub> crystal structure superimposed. Blue spheres represent W atoms, and yellow spheres represent Se. Scalebar: 1 nm. (d) High-resolution, Fourierfiltered HAADF-STEM image from the white-boxed region labeled "d" in (a) Scalebar: 4 nm. (e) High-resolution, Fourier-filtered HAADF-STEM image from the white-boxed region labeled "e" in (a). Scalebar: 4 nm. (f) Schematic of the WSe<sub>2</sub> crystal structure with armchair and zigzag planes indexed. (g) Plots of pixel count intensity for line scans taken along the armchair direction of the crystal lattice from the rectangular regions marked by dashed boxes in (b), (d), and (e).

homogeneous, and there is no evidence to suggest that the jagged edges are the result of triangular intergrowths.

Having identified through Raman and AFM mapping that the crystals appear to be structurally homogeneous, we assessed their photoemission properties through far-field photoluminescence (PL) measurements. An analysis of PL spectra collected at various points within a triangle-shaped crystal with mostly straight edges (WO<sub>3</sub>:NaCl ratio 10:1) reveals emission that varies significantly in intensity across the crystal but exhibits minor variation in peak wavelength or peak width (Figure S10). However, a similar point analysis of a crystal grown under higher W flux (WO<sub>3</sub>:NaCl ratio of 4:1) reveals not only variable and weaker emission intensity, but also a larger spread in peak wavelength and peak width compared to the straight-edge crystal (Figure S10). The emission centered at 778–780 nm, which we observe in the 10:1 crystal sample, is consistent with previous reports of exciton emission from grown and exfoliated 2D WSe<sub>2</sub> flakes.<sup>20</sup>

For a more detailed assessment of any spatial variation in the emission properties of the WSe<sub>2</sub> crystals, we obtained hyperspectral PL data. 2D TMD crystals exhibit strong coupling of light to excitonic states, which are themselves highly sensitive to local dielectric environment and other crystallographic features.<sup>11</sup> PL maps of a nearly straight-edged crystal, which was grown under conditions of a 10:1 WO<sub>3</sub>:NaCl ratio, reveal emission whose wavelength and bandwidth are spatially uniform across the crystal (Figure 5a, Figure S12). However, crystals prepared at 8:1 and 4:1 WO<sub>3</sub>:NaCl ratios (higher W flux) exhibit an increased disorder in their PL characteristics (Figure 5b,c). PL maps of crystals grown at a 4:1 ratio identify significant variations in emission wavelength, intensity, and bandwidth across the crystal (Figure 5c).

Parametric plots of emission peak wavelength, intensity, and bandwidth summarize the progression toward increased optical disorder as morphological disorder increases in crystals grown at increasingly higher W flux (Figure 5a-c). As one progresses from crystals synthesized at 10:1 to 4:1 ratios, there is a marked increase in dispersion of the peak emission wavelength and an increase in the bandwidth of these emission peaks. Moreover, much of the emission broadening and site-to-site variation in the emission bandwidth appears localized to a region within  $\sim 2 \ \mu m$  of the disordered edge of the crystal grown at a 4:1 ratio. Previous nano-optical characterization of 2D MoS<sub>2</sub> crystals identified a qualitatively similar dispersion in the emission energy and line-shape within energetically disordered regions located near the crystal edge.<sup>26</sup> A high density of edge protrusions, as in the case of WSe<sub>2</sub> growth at a 4:1 ratio, may cause increased lattice strain, as adjacent facets intersect. Lattice strain is known to alter overlap between atomic orbitals leading to shifted electronic bands, even when the strain field is localized to a few nanometers.<sup>48,49</sup> While in principle this strain could manifest as a Raman peak shift, we estimate from the observed 10-20 meV PL shifts that these crystals exhibit a modest lattice strain of less than 0.2%, which would render Raman peak shifts of less than 0.1 cm<sup>-1</sup> that are less than the measurement limit of our instrument.<sup>50,51</sup>

Strain introduced by a rapid shift from equilibrium growth conditions is the most plausible explanation for the observed shifts in the energy of and disorder in PL. However, we also sought to address the possibility that chemical doping may be responsible for the observed spatial variations in PL, as has recently been shown in CVD-grown TMDs.<sup>52</sup> X-ray photoelectron spectroscopy (XPS) of salt-assisted 2D WSe<sub>2</sub> crystals grown on SiO<sub>2</sub> substrates shows no photoelectron signal from either Na 1s (expected at 1072 eV) or Cl 2p (expected at 198 eV) states (Figure S13). These data indicate that neither Na nor Cl is incorporated into the crystal lattice or adsorbed onto its surface after reaction. Moreover, these results are consistent with both our analysis of the precursor chemistry through XRD and with studies from the literature that discuss the proposed reaction pathway for NaCl-assisted growth of TMDs.<sup>41,44</sup> In these reactions, Na-containing species remain in the solid state and can be collected from the ceramic vessel, while volatile tungsten oxyhalide species, which are the primary WSe<sub>2</sub> precursor, react with H<sub>2</sub> to form H<sub>2</sub>O and HCl byproducts, which remain in the gas phase to be expelled by the carrier gas.



**Figure 4.** (a–d) Intensity-normalized Raman maps of integrated E' peak intensity across a 2D WSe<sub>2</sub> crystal prepared at each of the ratios identified at top right. Scalebars: 10  $\mu$ m. (e) Representative normalized Raman spectra for each mapped crystal identify a uniform E' peak shift, line width, and profile. (f–i) AFM maps of crystals prepared at the listed ratios reveal the crystals to be of uniform height. Scalebars: 10  $\mu$ m. (j) High-resolution AFM map of an edge protrusion. Scalebar: 2  $\mu$ m.



**Figure 5.** (a) From top to bottom, a map of normalized PL peak intensity, a map of PL peak bandwidth expressed as full-width at half-maximum (fwhm), a map of PL peak wavelength, and a parametric plot showing PL peak center wavelength, peak intensity, and peak fwhm for a WSe<sub>2</sub> crystal grown at a WO<sub>3</sub>:NaCl ratio of (a) 10:1, (b) 8:1, and (c) 4:1. Scalebars: 10  $\mu$ m.

We propose that future experiments should address the nature of the precursor chemistry during the reaction, for instance through the use of in situ methods such as mass spectrometry or ex-situ EDS analysis of under-reacted crystals. Therefore, we propose that structural disorder introduced under high W flux conditions leads to residual lattice strain that in turn shifts the exciton or charged exciton populations to yield the disordered emission profile near the edge of the jagged crystals. Further studies, for instance on suspended or transferred crystals, will shed additional light on the nature of synthetically induced strain.

# CONCLUSION

In this study, we demonstrated that the transition metal precursor flux has a profound effect on the morphology and optical properties of 2D TMD crystals. We demonstrated systematic control over W precursor volatility, and thereby flux, by tuning the mass ratio of WO3:NaCl mixtures, and we note that salt-assisted approaches may beneficially reduce the need for additional reducing agents during synthesis of TMDs. We explain the steady evolution of the crystal morphology and identify the emergence of a disordered growth mode at high W flux that yields WSe<sub>2</sub> crystals with jagged edges. These jagged edges are composed of oriented facet protrusions that nucleate around the circumference of the crystal due to an imbalance between the  $W_{zz}$  and  $Se_{zz}$  facet growth kinetics. Though morphologically disordered at its edges, the crystal still retains its continuous monolayer character with no evidence of apparent intergrowths. PL mapping shows that broadened and spatially varying emission profiles, most likely resulting from excitonic disorder, correlate strongly with the degree of structural disorder in the crystal. Studies correlating synthetic parameters, material morphology, and optoelectronic properties are vital for advancing a unified understanding of limits and opportunities in synthetic 2D materials.

# METHODS

## Chemical Analysis of WO<sub>3</sub>:NaCl Precursors

Thermogravimetric analysis (TGA) of WO<sub>3</sub>:NaCl mixtures in ratios of 5:1, 10:1, and 15:1 was conducted with a PerkinElmer TGA 8000. The samples were measured under a nitrogen atmosphere with a N<sub>2</sub> flow rate of 20 mL/min while being heated from room temperature to 900 °C at a rate of 32 °C/min.

Powder X-ray diffraction (pXRD) data were collected on samples composed of mixtures of WO<sub>3</sub> and NaCl (at the stated ratios) that were annealed in an alumina crucible in the presence of a hydrogen and selenium atmosphere identical with that used in the CVD reactions. Room-temperature pXRD scans were collected on these powder samples on a Bruker D8 Focus diffractometer (Cu source K $\alpha$  = 8.04 keV, 1.5406 Å). Scans were taken over a 5–60° range with a 0.018585749° step size over 4 min.

#### Chemical Vapor Deposition Growth of WSe<sub>2</sub>

CVD growth of WSe<sub>2</sub> was conducted in a custom-built CVD reactor, the details of which have been described previously.<sup>16</sup> Briefly, a quartz tube was cleaned with alconox, rinsed with water and IPA, dried under a N<sub>2</sub> flow, and baked out at 500 °C for 30 min. WO<sub>3</sub> (99.8% metals basis, Alfa Aesar) and NaCl (99.0%, EMD) were then mixed at mass ratios between 45:1 and 4:1, while keeping the NaCl mass constant at 3.5 mg, and spread evenly over the bottom of an alumina boat. A SiO<sub>2</sub> on Si substrate (SiO<sub>2</sub> layer is 200 nm thick) was then placed face-down on the alumina boat so as to cover the WO<sub>3</sub>:NaCl powder. This substrate—boat ensemble was placed in the most downstream zone of our 3-zone furnace. A second alumina boat containing 200 mg of Se (99.5% metals basis, Alfa Aesar) was placed in the most upstream zone. The quartz tube was then evacuated to base pressure ( $\sim 1 \times 10^{-4}$  Torr) and pressurized to 5 Torr with 5 sccm of H<sub>2</sub> gas. The reactor was then heated to 850 °C over the course of 25 min and held at 850 °C for 3 min. After 3 min, the reaction was quenched by turning off the heating program and by flushing the reactor with 50 sccm of N<sub>2</sub> at 5 Torr. The furnace was cooled to room temperature.

## Physical Characterization of WSe<sub>2</sub> Crystals

Crystals were imaged with an optical microscope (Zeiss Axioscope A1), a scanning electron microscope (Tescan Mira), and an aberration-corrected scanning transmission electron microscope (Nion UltraSTEM200X). SEM images were collected through an in-lens detector at an acceleration voltage of 10 kV, a beam current of 102  $\mu$ A, and a working distance of 4 mm. Samples for STEM imaging were prepared by transferring 2D WSe<sub>2</sub> crystals with a polydimethylsiloxane (PDMS) stamp to a perforated SiN<sub>x</sub> membrane TEM grid. Briefly, a PDMS stamp is placed on the desired region of the growth substrate; this stack is then immersed in a 1 M KOH solution until the stamp delaminates with the crystals. Using a microscope slide to support the stamp and a home-built transfer stage, the crystals are stamped and released onto perforated areas of the SiN<sub>x</sub> membrane TEM grid. STEM images were collected by using high-angle annular dark field (HAADF) detection at an operating voltage of 60 kV with a nominal probe current and size of 30 pA and 120 pm, respectively. Optical and SEM images were analyzed with ImageJ to extract crystal sizes; edge protrusions were counted manually, and STEM-HAADF data were processed using Gatan DigitalMicrograph v3 for Fourierfiltering of images.

PL spectra shown in Figure 4 were taken with a Horiba Jobin Yvon T46000 spectrometer and a liquid N<sub>2</sub>-cooled CCD detector. Excitation with an Ar<sup>+</sup>/Kr<sup>+</sup> laser at 514 nm and 1 mW was focused through a 100x objective (Olympus) to a spot size of less than 1  $\mu$ m. Raman and PL mapping was conducted on a LabRam Aramis (Horiba) system equipped with a Synapse spectrometer. Laser excitation at  $\lambda = 532$  nm and a power of 1 mW was provided with a solid state laser focused through a 100× objective (Olympus) to a spot size of less than 1  $\mu$ m. Raman and PL data were analyzed with Python, and an example of the data analyses performed can be found in Figure S11.

AFM maps were acquired on an MFP-3D (Asylum) AFM instrument operating in tapping mode with Si tips. AFM data were analyzed with Gwyddion.

# ASSOCIATED CONTENT

#### **Supporting Information**

The Supporting Information is available free of charge at https://pubs.acs.org/doi/10.1021/acsnanoscienceau.3c00028.

(i) pXRD data of precursor, (ii) SEM and optical images of WSe<sub>2</sub> crystals, (iii) statistical analyses, (iv) TEM data,
(v) Raman spectra, (vi) AFM scans, (vii) photo-luminescence spectra, and (viii) XPS data (PDF)

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## **Author Contributions**

R.D.G. and T.J.K. conceived the study and designed experiments. R.D.G. and T.C. performed initial syntheses. R.D.G. performed subsequent syntheses with assistance from S.H. and O.A. Y.Z. collected pXRD data. R.D.G. performed structural and optical characterization of crystals. R.D.G., T.H.B., and B.H. prepared samples and collected scanning transmission electron microscopy data. S.S. performed image analysis. R.D.G., T.C., and T.J.K. wrote the manuscript with input from all authors. All authors have given approval to the final version of the manuscript. CRediT: Reynolds Dziobek-Garrett conceptualization (equal), data curation (equal), formal analysis (equal), investigation (equal), validation (equal), visualization (equal), writing-original draft (equal), writing-review & editing (equal); Sachi Hilliard investigation (equal), validation (equal); Shreya Sriramineni investigation (equal), software (equal); Ona Ambrozaite investigation (equal), validation (equal); Yifei Zhu investigation (equal), validation (equal); Bethany M. Hudak formal analysis (equal), investigation (equal); Todd H. Brintlinger formal analysis (equal), investigation (equal); Tomojit Chowdhury investigation (equal), methodology (equal); Thomas J Kempa conceptualization (equal), data curation (equal), formal analysis (equal), funding acquisition (lead), methodology (lead), project administration (lead), resources (lead), software (equal), supervision (lead), visualization (equal), writing-original draft (equal), writing-review & editing (lead). Funding

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## Notes

The authors declare no competing financial interest.

# **ABBREVIATIONS**

TMD, transition metal dichalcogenide; CVD, chemical vapor deposition; PL, photoluminescence; OM, optical microscopy; SEM, scanning electron microscopy; AFM, atomic force microscopy; TGA, thermogravimetric analysis; pXRD, powder X-ray diffraction

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